AN ELECTROLYTIC CIP-CLEANING PROCESS FOR REMOVING IMPURITIES FROM THE INNER SURFACE OF A METALLIC CONTAINER

The invention relates to a novel electrolytic process for removing impurities from the inner surface of a metallic container. The process is particularly useful for cleaning process reactors used for culturing microorganisms, and storage tanks used for storing metabolites formed in the process reactor, as well as containers for dairy products.

General information
State: Published
Organisations: Materials and Surface Engineering, Department of Mechanical Engineering
Contributors: Møller, P., Minzari, D., Schreiner Hansen, J.
Publication date: 2008

Publication information
Patent number: WO2008110587
Date: 18/09/2008
Original language: English

Bibliographical note
International application published under the World Intellectual Property Organization (WIPO)
Source: orbit
Source-ID: 266092
Research output: Research › Patent – Annual report year: 2008